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APPLICANT
Feiling Wang, et al.

FILING DATE
November 17, 2000

GROUP
2873



U.S. PATENT DOCUMENTS

EXAM- INER INI- TIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB- CLASS	FILING DATE IF APPROPRIATE
T.T.	AA	6,211,993 B1	04/03/01	Wang, et al.	359	260	—
	AB						
	AC						
	AD						

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB- CLASS	TRANSLATION YES NO	
T.T.	AL	04 018767 A	22/JAN/92	Abstract of Japan	/	/	X	
T.T.	AM	1 172 852 A	03/DEC/69	Great Britain	/	/		
T.T.	AN	2 261 522 A	19/MAY/93	Great Britain	/	/		
T.T.	AO	0 380 326 A2	01/AUG/90	EPO	/	/		
	AP							
	AQ							

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

T.T.	AR	Wang, F., et al., "Large Electrooptic Modulation Using Ferroelectric Thin Films in a Fabry-Perot Cavity," <i>Proceedings of the IEEE International Symposium on Applications of Ferroelectrics</i> 9:683-686 (1994).
T.T.	AS	Tsen-Hwang, L., et al., "Two-Dimensional Spatial Light Modulators Fabricated in SI/PLTZ," <i>Applied Optics</i> 29(11): 1595-1603 (1990).
T.T.	AT	Li, K. K., et al., "An automatic dip coating process for dielectric thin and thick films," <i>Integrated Ferroelectrics</i> 3(1):81-91 (1993).
T.T.	AU	Wang, F., et al., "Ferroelectric-on-silicon modulators for high-density optical interconnects," <i>Conference on Lasers and Electro-Optics, CLEO '98</i> , 414 (May 3-8, 1998).
T.T.	AV	Wang, F. and Haertling, G.H., "Integrated reflection light modulator using ferroelectric films on silicon," <i>Conference on Lasers and Electro-Optics, Maryland, CLEO '95</i> 302 (May 22-26, 1995).
T.T.	AW	Wang, F., et al., "Electro-optic measurements of thin-film materials by means of reflection differential ellipsometry," <i>J. Appl. Phys.</i> 78(1), July 2, 1995.

EXAMINER

TUYEN TRA

DATE CONSIDERED

4.22.02